Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L13	7	(((257/303) or (257/310) or (438/240) or (438/387) or (438/397)).CCLS.) and (("tantalum oxide" or "tantalum pentoxide" or "ta.sub.2o.sub.5" or tao or "ta.sub.xo.sub.y") with oxidation with (degree or level))	US-PGPUB; USPAT	OR	ON	2005/10/14 09:00
L12	26	11 and oxidation with degree	US-PGPUB; USPAT	OR	ON	2005/10/14 09:00
L11	1024	(((257/303) or (257/310) or (438/240) or (438/387) or (438/397)).CCLS.) and ("tantalum oxide" or "tantalum pentoxide" or "ta.sub.2o.sub.5" or tao or "ta.sub.xo.sub.y")	US-PGPUB; USPAT	OR	ON	2005/10/14 09:00
S17	69	(((257/303) or (257/310) or (438/240) or (438/387) or (438/397)).CCLS.) and (("tantalum oxide" or "tantalum pentoxide" or "ta.sub.2o.sub.5" or tao or "ta.sub.xo.sub.y") and ("atomic layer deposition" or "atomic layer epitaxy" or ald or ale))	US-PGPUB; USPAT	OR	ON	2005/10/14 08:59
S13	840	(((257/303) or (257/310) or (438/240) or (438/387) or (438/397)).CCLS.) and ("tantalum oxide" or "tantalum pentoxide" or "ta.sub.2o.sub.5" or tao or "ta.sub.xo.sub.y")	US-PGPUB; USPAT	OR	ON	2005/10/14 08:59
L10	126	(((257/303) or (257/310) or (438/240) or (438/387) or (438/397)).CCLS.) and (("tantalum oxide" or "tantalum pentoxide" or "ta.sub.2o.sub.5" or tao or "ta.sub.xo.sub.y") and ("atomic layer deposition" or "atomic layer epitaxy" or ald or ale))	US-PGPUB; USPAT	OR	ON	2005/10/14 08:59
L9	1	("6228702").PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/10/14 08:29
S61	1	("20040077493").PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/10/05 10:23
S60	2	metal with rich with oxidation with number	US-PGPUB; USPAT	OR	ON	2005/10/05 10:23